Date Mailed: November 27, 2001

Paper No. 4

Sheet 1 of 1

FORM 1449*

INFORMATION DISCLOSURE STATEMENT

IN AN APPLICATION

(Use several sheets if necessary)

Docket Number: AMDA.497PA	Application Number: 09/864,666
Applicant: Ring et al.	
Filing Date: 5/23/2001	Group Art Unit: 1746

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U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

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FOREIGN PATENT DOCUMENTS

	DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
						YES	NO

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

L.T.N-E.	1999	K. Edinger, "Gas Assisted Etching of Copper with Focused Ion Beams", J. Vac. Sci. Technol., November/December 1999.

EXAMINER Lynette T. Umez-Eronini	DATE CONSIDERED 5/20/2003

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form for next communication to the Applicant.

*Substitute Disclosure Statement Form (PTO-1449)